2125

PATENT APPLICATION

00862.022199.



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application	on of:)	E	D. D. 4!.	
Keiji EMO	O			;) ;		er: P. Rodrig Art Unit: 212	
Application No	.: 09/833,766)	-		
Filed: April 13, 2001					Confirm	nation No.:	4154
For: PIPE STRUCTURE, ALIGNMENT APPARATUS, ELECTRON BEAM LITHOGRAPHY APPARATUS, EXPOSURE APPARATUS, EXPOSURE APPARATUS MAINTENANCE METHOD, SEMICONDUCTOR DEVICE MANUFACTURING METHOD, AND SEMICONDUCTOR MANUFACTURING FACTORY					Novemb	PECE	EIVED 5 2003
Commissioner P.O. Box 1450						Technolog)	Center 2100
Alexandria, VA	A 22313-1450						
Sir:							
Transmitted he identified appli		endment ar	nd Letter Forwardin	g Subs	titute Spe	cification in	the above-
No ac	ditional fee is re	equired.					
The fee has bee	en calculated as s	shown belo	w:				
			CLAIMS AS AMEN	DED			
	CLAIMS REMAINING		HIGHEST NO.				

		,	CLAIMS AS AME	NDED		
	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL CLAIMS	27	MINUS	25	= 2	x \$9 \$18	\$36.00
INDEP. CLAIMS	11	MINUS	3	= 8	x \$43 \$86	\$688.00
Fee for Multiple Dependent claims \$145/\$290						_
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT						\$724.00

	°Verified Statement claiming small entity status is enclosed, if not filed previously.
X	A check in the amount of \$724.00 is enclosed including the additional claims fee.
	Charge \$ to Deposit Account No. 06-1205. A duplicate of this sheet is enclosed.
X	Any prior general authorization to charge an issue fee under 37 CFR 1.18 to Deposit Account No. 06-1205 is hereby revoked. The Commissioner is hereby authorized to charge any additional fee under 37 CFR 1.16 and 1.17 which may be required during the entire pendency of this application or to credit any overpayment, to Deposit Account No. 06-1205. A duplicate of this paper is enclosed.
	A check in the amount of \$ to cover the fee for a two month extension is enclosed.
	A check in the amount of \$ to cover the Information Disclosure Statement fee is enclosed.
X	Applicant's undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should be directed to our address given below.
	Respectfully submitted,
	Attorney for Applicant Steven E. Warner Registration No. 33,326

FITZPATRICK, CELLA, HARPER & SCINTO 30 Rockefeller Plaza
New York, New York 10112-3801
Facsimile: (212) 218-2200
SEW/eab

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Alexandria, VA 22313-1450

PATENT APPLICATION

#9

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
	: Examiner: P. Rodriguez
Keiji EMOTO)
	: Group Art Unit: 2125
Application No.: 09/833,766)
	: Confirmation No.: 4154
Filed: April 13, 2001)
E DIDE CONTROL ALICAN CENTE ADDADA MAIO	:
For: PIPE STRUCTURE, ALIGNMENT APPARATUS,) November 19, 2003
ELECTRON BEAM LITHOGRAPHY	:
APPARATUS, EXPOSURE APPARATUS,	
EXPOSURE APPARATUS MAINTENANCE	RECEIVED
METHOD, SEMICONDUCTOR DEVICE)
MANUFACTURING METHOD, AND SEMI-	NOV 2 5 2003
CONDUCTOR MANUFACTURING FACTORY) Center 2100
) NOV 2 3 2 3 2 3 2 3 2 3 2 3 2 3 2 3 2 3 2
Commissioner for Patents	
P.O. Box 1450	

REQUEST FOR APPROVAL OF DRAWING CHANGES

Sir:

Applicant requests that the Examiner approve the changes to Figure 12, as shown in red on the attached sketch, enclosed in duplicate.

In Figure 12, under "FIG. 12" insert -- PRIOR ART --, "101" should read -- 501 --, "102" should read -- 502 --, "103" should read -- 503 --, "104" should read -- 504 --, "105" should read -- 505 --, and both occurrences of "106" should read -- 506 --, as shown.

Favorable consideration is requested.

Applicant's undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010 All correspondence should continue to be directed to our address given below.

Respectfully submitted,

Attorney for Applicant

Steven E. Warner

Registration No. 33,326

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